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# Dellafossite $\text{CuAlO}_2$ film growth and conversion to $\text{Cu-Al}_2\text{O}_3$ metal ceramic composite via control of annealing atmospheres

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In this work we demonstrate simple techniques to form well crystallised  $\text{CuAlO}_2$  powders and thick films from  $\text{CuO}$  and boehmite or alumina, using a novel molten salt painting process. We examine the formation mechanism using X-ray diffraction, scanning electron microscopy, energy dispersive X-ray spectroscopy and in situ high temperature X-ray diffraction and find that the annealing atmosphere plays a critical role. From this we develop a method to create  $\text{Cu-Al}_2\text{O}_3$  conductive metal-ceramic composite materials with novel morphologies via the thermal decomposition of  $\text{CuAlO}_2$  precursor films.

## 1. Introduction

There is a growing interest in transparent wide bandgap p-type semiconductor oxides as they may become an essential component in the development of next generation devices in areas such as transparent electronics and solid state UV optoelectronics.<sup>1-3</sup> The discovery of intrinsic wide bandgap p-type conduction in the dellafossite material  $\text{CuAlO}_2$  represents an important step towards realising these technologies.<sup>4</sup> In addition  $\text{CuAlO}_2$  as been demonstrated as an effective catalyst for solar water splitting and chlorine production and may also have applications in low power field emission based displays and sensor technologies.<sup>5-8</sup> Another area, also of increasing interest, is metal ceramic composite (MCC) materials, such as  $\text{Cu-Al}_2\text{O}_3$ , which have been shown to have favourable properties for many applications, such as high wear resistant conductive coatings, electrodes and structural applications.<sup>9-11</sup>

Many different techniques to form  $\text{CuAlO}_2$  films and powders have been demonstrated including sol-gel, hydrothermal, pulsed laser deposition, MO-CVD and solid state reactions.<sup>12-19</sup> Preparing  $\text{CuAlO}_2$  using high temperature methods is challenging due to the complex Cu-Al phase diagram.<sup>20</sup> Normally it is considered essential to ensure that the Cu and Al are intimately mixed in order to achieve a phase pure material and this requirement necessitates remixing and multiple anneals when preparing powders using solid state methods. In contrast, by complexing the  $\text{Cu}^{2+}$  during sol-gel preparation methods phase separation can be inhibited leading to phase pure material, which

can be obtained in a single anneal. Subsequent burn out of the complexing agent leads to a final porous material morphology with many holes in the film.<sup>21</sup> Recently it has been shown that  $\text{CuAlO}_2$  films with excellent optical properties can be prepared by the interfacial reaction between  $\text{Cu}_2\text{O}$  and sapphire substrates using a sandwich structure to inhibit the molten  $\text{Cu}_2\text{O}$  from beading on the substrate surface due to surface tension.<sup>22-23</sup> For catalytic applications and for MCCs the use of sapphire is less desirable owing to its high cost and brittleness.

In this work we will demonstrate simple techniques for the synthesis of  $\text{CuAlO}_2$  powders and films on  $\text{Al}_2\text{O}_3$  ceramic substrates and their conversion to a MCC, showing the potential  $\text{CuAlO}_2$  offers in the synthesis of MCCs, e.g. for durable wear resistant conductive ceramics. The initial  $\text{CuAlO}_2$  film deposition process involves a novel molten salt painting procedure, that with suitable adaption, could be used to coat complex ceramic geometries.

## 2. Experimental

### 2.1 Preparation of $\text{CuAlO}_2$ reference powder

$\text{CuAlO}_2$  reference powder was prepared by a solid state reaction between boehmite and  $\text{CuO}$ . Aluminium isopropoxide was added in small portions to  $\text{DI-H}_2\text{O}$  preheated to  $80^\circ\text{C}$  under vigorous stirring.  $\text{CuO}$  powder was then added to the resultant boehmite gel. The molar ratio of Al to Cu was 0.3. The excess water and isopropanol by-product was evaporated from the gel whilst maintaining the vigorous stirring until the viscosity of the gel had

increased to the point where no CuO sedimentation took place. The viscous gel was then transferred to a PTFE dish and heated at 200°C for several hours. During drying an easily handled semi-solid cake formed which was then transferred to a pre-heated furnace at 1100°C for 5 hours. After calcination the cake was quickly removed from the furnace under a nitrogen stream and cooled to room temperature. The excess Cu<sub>x</sub>O was then removed by grinding the cake in 36% HCl. The CuAlO<sub>2</sub> powder was recovered by vacuum filtration and the filter cake was washed with several aliquots of 36% HCl before being washed with water and then isopropanol and finally dried at 60°C for 24 hours. Excess copper can then be easily recovered from the filtrate.

## 2.2 Preparation of CuAlO<sub>2</sub> films on Al<sub>2</sub>O<sub>3</sub>

Sintered Al<sub>2</sub>O<sub>3</sub> plates 7.5cm x 7.5cm x 1mm were cut into 1 x 2 cm sized samples and cleaned by sonication in acetone and water and gently dried with a nitrogen stream. Copper nitrate was then painted onto the substrate surface in a simple coating procedure. A few crystals of copper nitrate were placed on the surface of the substrate which was then heated to 150°C on a hotplate. When the nitrate salt melted, a small pin was used to paint the entire substrate with the molten salt. After a few minutes heating the molten nitrate lost its water of crystallisation resulting in a dry copper hydroxyl nitrate gel. Over the course of 15 minutes the temperature was increased to 300°C so as to decompose the nitrate, leaving a CuO film on the substrate surface. The coated substrate was then inserted into a pre-heated furnace at 1100°C and heating continued for a further 5 hours to form a CuAlO<sub>2</sub> film. The substrates were quickly removed from the furnace under a stream of nitrogen and cooled to room temperature. Excess Cu<sub>x</sub>O was removed by soaking the substrate in 36% HCl for 10 minutes, rinsing with fresh HCl, DI-H<sub>2</sub>O and dried at 60°C for 1 hour. The entire coating process was then repeated to ensure a uniform and complete coating across the substrate.

## 2.3 Characterisation and thermal decomposition

The morphologies and crystal structures of the powders and films were examined using scanning electron microscopy (SEM: Karl-Zeiss EVO series) and x-ray diffraction (XRD: Bruker AXS D8 Advance Texture Diffractometer). In situ high temperature XRD measurements and CuAlO<sub>2</sub> decompositions were performed using a Jordan Valley D1 Evolution XRD fitted with an Anton Paar DHS1100 domed hot stage.

## 3. Results

### 3.1 CuAlO<sub>2</sub> powder

CuAlO<sub>2</sub> powders prepared by high temperature solid state reactions from mixtures of boehmite gel and CuO showed a good deal of variability in their composition depending on the stoichiometry of reactants used. As shown by the powder XRD data in figure 1(i), samples prepared with a direct 1:1 ratio of [Al] and [Cu] typically had component peaks due to Al<sub>2</sub>O<sub>3</sub>, indicating an incomplete consumption of the boehmite most likely due to inadequate intermixing of the two reactants. Metallic copper reflections were also detected at 2θ values of 43.3° and 50.4°, corresponding to PDF card no: 04-0836. To eliminate phase impurities, samples are typically re-ground, pressed and re-annealed. In the absence of high pressure pelletisation, re-annealing the as-prepared powders (figure 1 (ii)), leads to a large

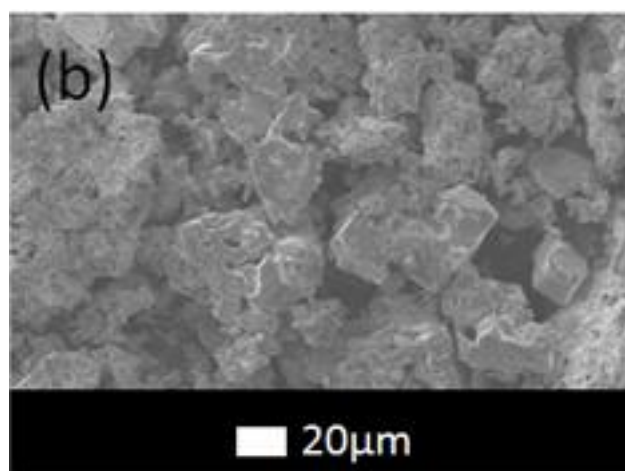
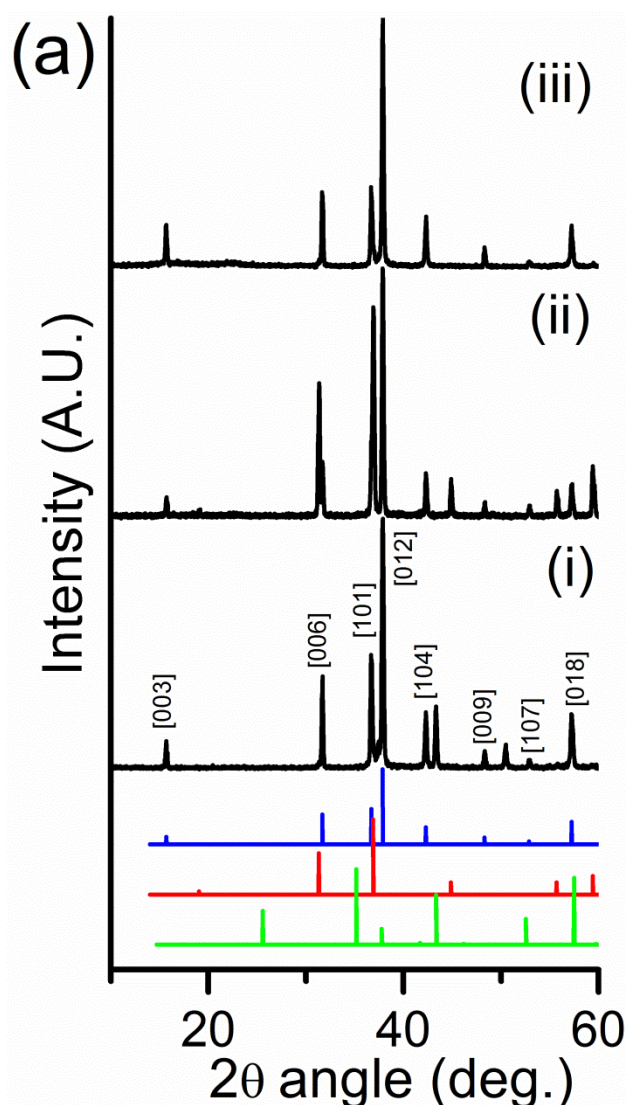


Figure 1: (a) XRD data showing CuAlO<sub>2</sub> powder made from boehmite and CuO using [Cu]/[Al] ratios of (i) 1:1 with single anneal at 1100°C (ii) 1:1 with 2 anneals at 1100°C (iii) 3:1 with single 1100°C anneal. The blue, red and green lines indicate the peak positions of CuAlO<sub>2</sub> (PDF card no: 35-1401), CuAl<sub>2</sub>O<sub>4</sub> (PDF card no: 33-0448) and Al<sub>2</sub>O<sub>3</sub> (PDF card no: 46-1212), respectively. (b) SEM image showing the CuAlO<sub>2</sub> powder corresponding to the XRD data shown in (iii).



increase in the spinel  $\text{CuAl}_2\text{O}_4$  impurity phase as evidenced by the increase of the (220) peak at  $2\theta = 31.3^\circ$  and (400) peak at  $2\theta = 44.9^\circ$ .

As compared to other recent reports using boehmite in conjunction with copper salt precursors where residual impurities remained,<sup>24</sup> it was found that phase pure  $\text{CuAlO}_2$  powder can be prepared by a single anneal by using an excess of  $\text{CuO}$ . The XRD data in figure 1 (iii) reveal that, ratios of 3:1  $[\text{Cu}]/[\text{Al}]$  were sufficient to ensure the complete conversion of the boehmite precursor without the formation of any impurity phases such as residual boehmite or  $\text{Al}_2\text{O}_3$ . Close inspection of the XRD pattern baseline did not reveal any impurity related diffractions indicating that the material is phase pure. The relative intensities of the  $\text{CuAlO}_2$  peaks identified closely match those of the PDF card 35-1401. The excess copper, which according to the phase diagrams is most likely a mixture of both  $\text{CuO}$  and  $\text{Cu}_2\text{O}$ , can easily be removed and subsequently recovered by soaking the as-prepared powders in concentrated  $\text{HCl}$  and filtering.<sup>20</sup> SEM analysis reveal that the phase pure powder is composed of a mixture of morphologies including bulky aggregates of smaller particles along with large well crystallised particles with sizes ranging

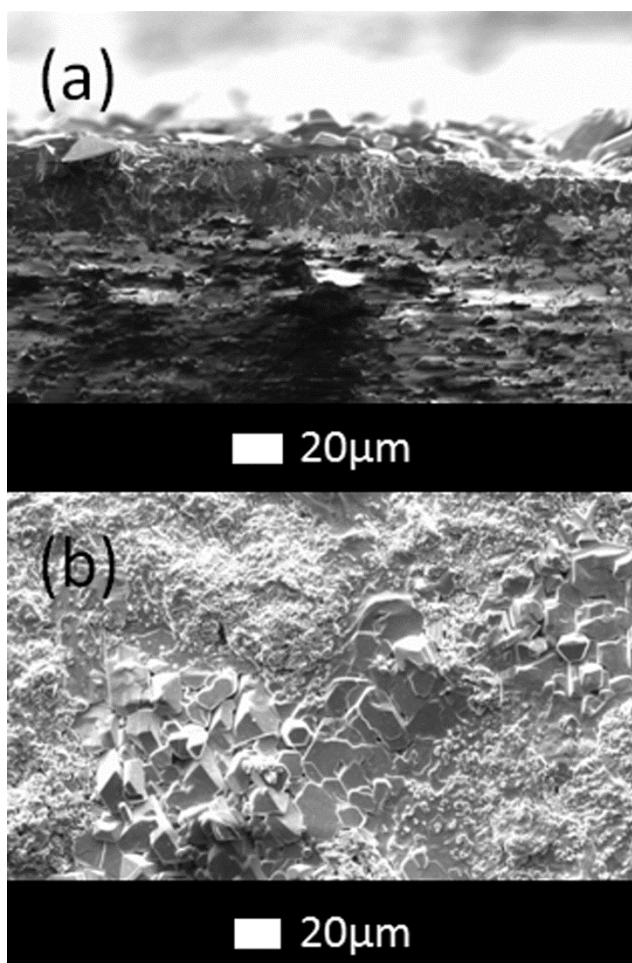


Figure 2: SEM image of (a) cleaved edge and (b) plan view of a  $\text{CuAlO}_2$  film on  $\text{Al}_2\text{O}_3$  substrate.

from hundreds of nm up to 40-50  $\mu\text{m}$ . Most of the particles are significantly larger than either the  $\text{CuO}$  or boehmite source powder particles.  $\text{CuO}$  has previously been used as a flux to grow  $\text{CuAlO}_2$  single crystals.<sup>18-19</sup> In this case we speculate that the excess  $\text{CuO}$  may be contributing to the enlarged crystal by acting as a flux, however a number of other explanations are also possible such as the formation of a eutectic or peritectic.

### 3.2 $\text{CuAlO}_2$ Thick films

Thick  $\text{CuAlO}_2$  films were successfully prepared using the straightforward procedure outlined in the experimental section. The as-prepared films were black in colour and covered the substrates uniformly after two deposition cycles. While many samples had complete substrate coverage after a single deposition cycle, some samples had small gaps in the films where part of the  $\text{CuO}$  coating dewetted during the annealing step. The SEM images in figure 2 show that the films produced by this technique were typically between 10 and 30  $\mu\text{m}$  thick. The thickness range was similar from sample to sample and did not appear to be dependent on the  $\text{CuO}$  coating thickness.

Similar to the  $\text{CuAlO}_2$  powders, the films were composed of a variety of particle sizes, ranging from 1-2  $\mu\text{m}$  to larger 20-30  $\mu\text{m}$  crystals. Cross-sectional SEM analysis reveals that the films vary

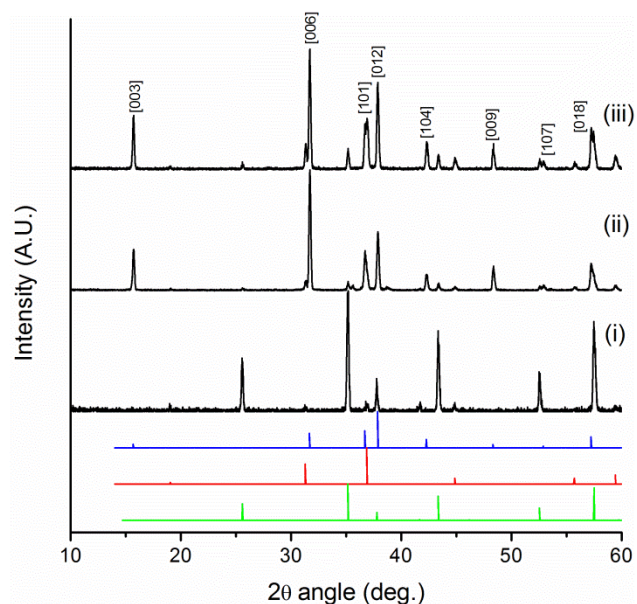


Figure 3: XRD data showing (i) the  $\text{Al}_2\text{O}_3$  substrate (ii)  $\text{CuAlO}_2$  film made from the interfacial reaction between  $\text{CuO}$  and  $\text{Al}_2\text{O}_3$  substrates with 2 deposition cycles (iii) with 2 deposition cycles and a 3<sup>rd</sup> anneal at 1100  $^\circ\text{C}$  with the  $\text{CuO}$  film removed. The blue, red and green lines indicate the peak positions of  $\text{CuAlO}_2$  (PDF card no: 35-1401),  $\text{CuAl}_2\text{O}_4$  (PDF card no: 33-0448) and  $\text{Al}_2\text{O}_3$  (PDF card no: 46-1212), respectively.

from being quite dense to slightly porous in some regions. XRD analysis, as shown in figure 3 (ii), indicates that  $\text{CuAlO}_2$  is the dominant constituent of the film. However, on close inspection, weak diffractions peaks are detected at  $2\theta = 31.3^\circ$  and  $55.7^\circ$  which are not associated with the substrate (figure 3 (i)) but correspond to spinel impurity phase  $\text{CuAl}_2\text{O}_4$  (220) and (422) planes. After the second deposition cycle, re-annealing the sample as shown in figure 3 (iii), leads to an increase in the impurity spinel phase, which suggests that once formed the spinel

is quite stable and thus difficult to remove. The relative intensity of the  $\text{CuAlO}_2$  diffraction peaks vary substantially as compared to the reference powder spectra shown in figure 1 (a), implying a texture in the film. Increases are seen in the  $2\theta$  peaks located at  $15.7^\circ$  and  $31.7^\circ$  corresponding to the (003) and (006) planes, indicating a preferential growth along the [001] direction.

To further understand the dynamics of the reactions taking place during sintering,  $\text{CuO}$  and  $\text{CuAlO}_2$  films on  $\text{Al}_2\text{O}_3$  were monitored by in situ XRD at  $1050^\circ\text{C}$  and  $1100^\circ\text{C}$ , respectively. Previously, it has been found that the interfacial reaction between  $\text{Al}_2\text{O}_3$  and  $\text{CuO}$  is the origin of the  $\text{CuAl}_2\text{O}_4$  spinel impurity<sup>22-23</sup>, whilst earlier studies of the interfacial reaction between  $\text{CuO}$ ,  $\text{Cu}_2\text{O}$  and  $\text{Al}_2\text{O}_3$  have indicated that  $\text{CuAl}_2\text{O}_4$  preferentially grows on the (0001) plane and  $\text{CuAlO}_2$  grows on the (11-20).<sup>25</sup> In this work, the polycrystalline  $\text{Al}_2\text{O}_3$  substrates used have x-ray reflections corresponding to both the (0001) and (11-20) planes and these are used in conjunction with  $\text{CuO}$  thereby satisfying conditions identified in previous work for both  $\text{CuAl}_2\text{O}_4$  and  $\text{CuAlO}_2$  formation. However, our results in figure 4 below show that, post annealing, only a very small fraction of the films are in the spinel phase.

It should be noted that the XRD scan range shown in figure 4 and time durations were chosen so as to effectively monitor changes in the sample composition in real time. Each scan lasted 8 minutes and the  $2\theta$  range  $30 - 40^\circ$  was chosen as all the components of interest have reasonably strong reflections in this range. At higher temperatures, thermal expansion effects shift the peak positions with respect to room temperature, however the substrate peak provides a useful reference point for the identification of the other components. In addition, peaks remaining at the end of the reaction period were tracked back to room temperature to confirm their assignments. XRD data prior to annealing are shown in figure 4 and curve (i) in figure 4(a) shows reflections at  $32.5^\circ$ ,  $35.5^\circ$  and  $38.7^\circ$  corresponding to the (-110) (002) and (111) planes of  $\text{CuO}$ . The broad FWHM suggest that the dimensions in the crystallographic directions being examined in this region are quite small. SEM images (not shown) of the  $\text{CuO}$  film prior to annealing, show that the film is composed of  $\text{CuO}$  nanoblades approximately 100 - 120 nm thick with a cross sectional diameter between 200 and 1000 nm. In the first 8 minutes at  $1050^\circ\text{C}$  (curve (ii) of figure 4(a)) the  $\text{CuO}$  reflections increase in intensity and the peak FWHM decreases. This is most probably due to the sintering behaviour of  $\text{CuO}$  at high temperature leading to the fusing of smaller grains into larger denser structures and amorphous  $\text{CuO}$  crystallising.<sup>26</sup> A new weaker peak emerges at  $36.3^\circ$  which is assigned to the  $\text{Cu}_2\text{O}$  (111) reflection. During the 8-16 minute scan, the  $\text{CuO}$  peaks completely disappear and are replaced by a dominant  $\text{Cu}_2\text{O}$  peak. After 16 minutes, the  $\text{Cu}_2\text{O}$  film has largely decomposed into metallic copper and alumina (curve (i) of figure 4(c)). In addition to the dominant copper and alumina components a number of weaker diffractions are detected at  $2\theta = 32.8^\circ$ ,  $36.3^\circ$ ,  $37.6^\circ$ ,  $44.0^\circ$ ,  $44.7^\circ$ ,  $51.4^\circ$  and  $59.3^\circ$  which are tentatively ascribed to  $\text{CuO}$  and  $\text{CuAl}_2\text{O}_4$  and different phases of  $\text{Al}_2\text{O}_3$ . However, the exact origin of these impurities has yet to be determined.

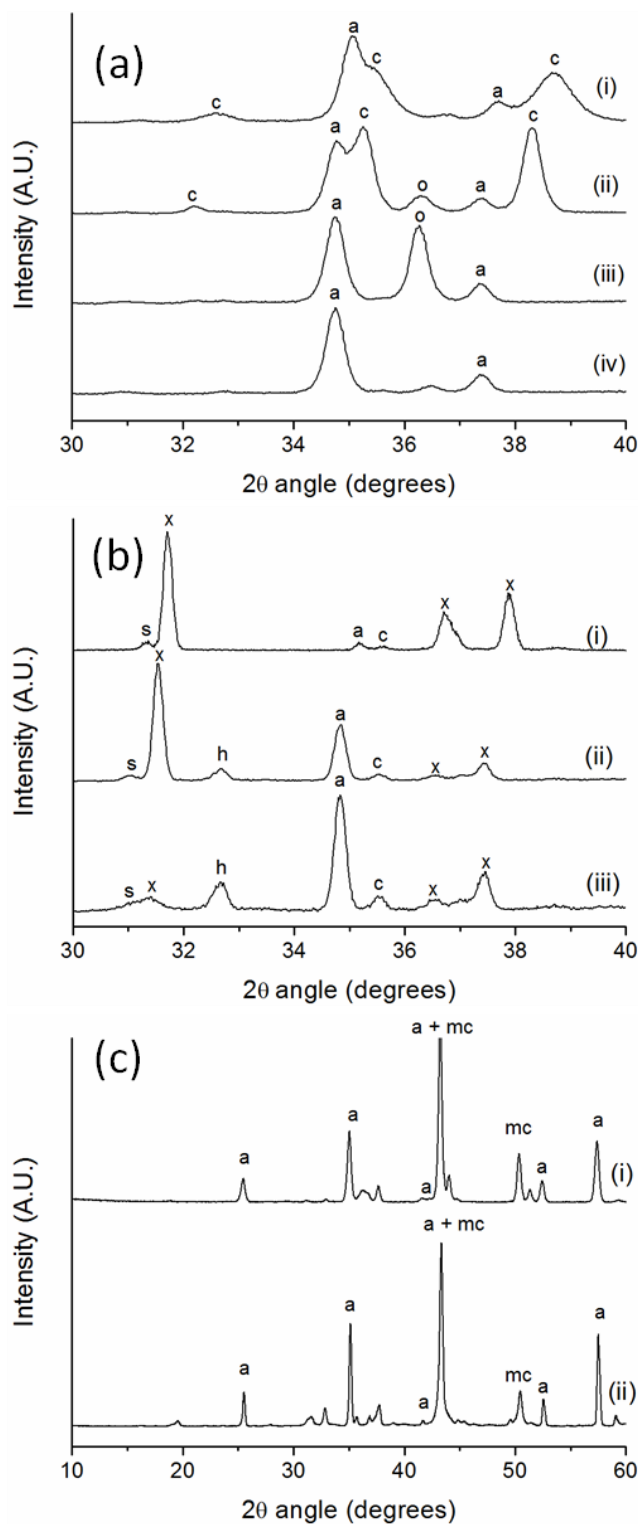


Figure 4: XRD data of (a)  $\text{CuO}$  coated on  $\text{Al}_2\text{O}_3$  at (i) room temperature (ii)  $1050^\circ\text{C}$ , 0-8 mins (iii)  $1050^\circ\text{C}$  8-16 mins (iv)  $1050^\circ\text{C}$  16-24 mins. (b)  $\text{CuAlO}_2$  coated on  $\text{Al}_2\text{O}_3$  at (i) room temperature (ii)  $1100^\circ\text{C}$  0-8 mins (iii)  $1100^\circ\text{C}$  8-16 mins (c) room temperature diffractogram of (i)  $\text{CuO}$  coated on  $\text{Al}_2\text{O}_3$  post annealing at room temperature (ii)  $\text{CuAlO}_2$  coated on  $\text{Al}_2\text{O}_3$  post annealing (c =  $\text{CuO}$ , a =  $\text{Al}_2\text{O}_3$ , o =  $\text{Cu}_2\text{O}$ , mc = metallic copper s =  $\text{CuAl}_2\text{O}_4$ , x =  $\text{CuAlO}_2$  h =  $\text{AlN}$  heating stage)

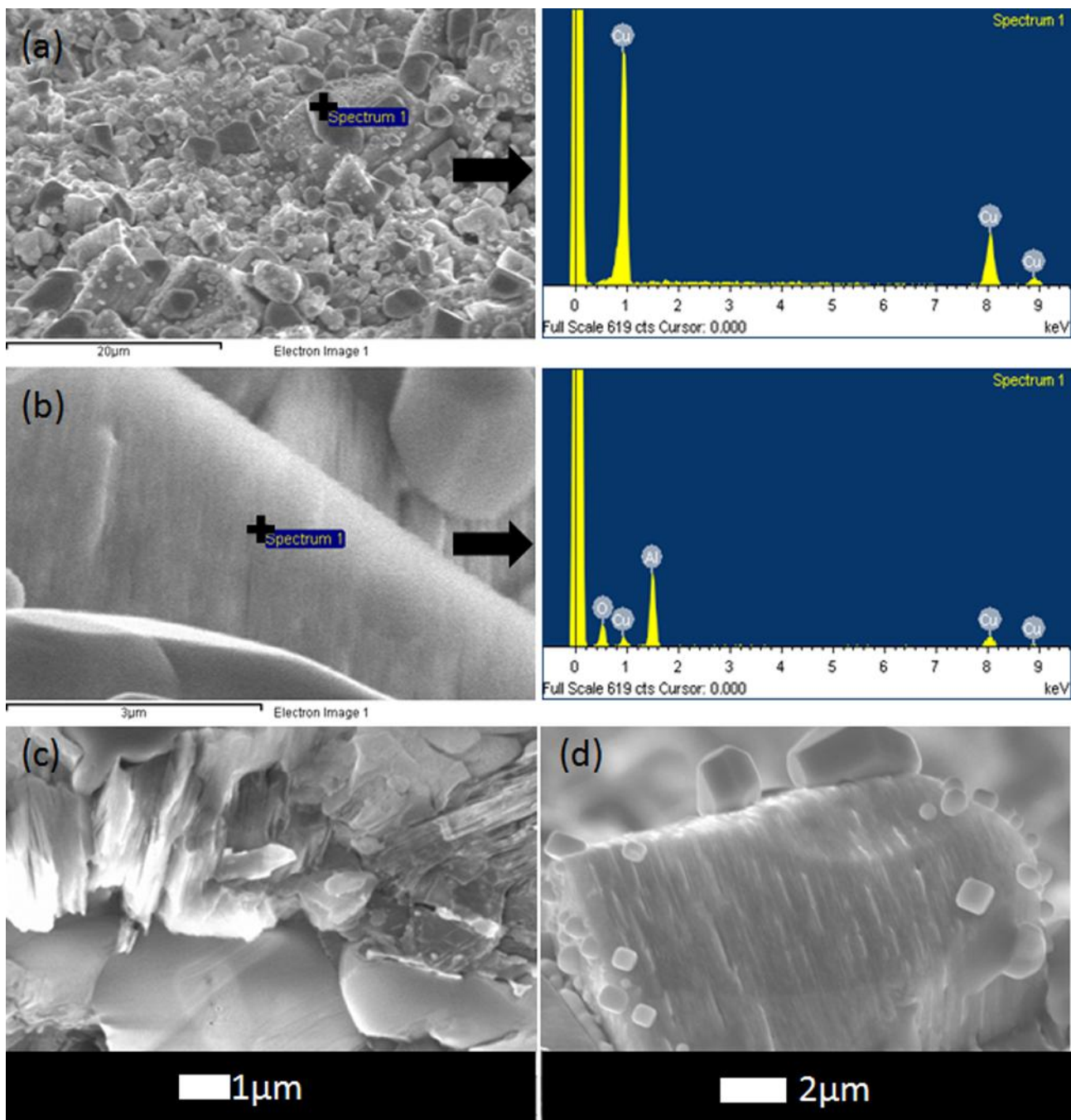


Figure 5: (a) SEM image and EDX spectra of the well faceted discontinuous surface coating. (b) SEM image and EDX spectra of the larger grains of the film coating. (c) and (d) SEM images of the bulk film, highlighting the stratification of the grains.

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From these XRD data some interesting points emerge. During this set of experiments, very little copper aluminates were detected, implying the amount formed was very limited (at least at the detection limit of the present measurement). During the initial heating period and during the first 8 minutes when CuO was major component of the film, no  $\text{CuAl}_2\text{O}_4$  was detected, nor was any  $\text{CuAlO}_2$  detected during the second 8 minutes when  $\text{Cu}_2\text{O}$  was the dominant species present. In addition, the final product formed was metallic copper. The conversion of CuO to

$\text{Cu}_2\text{O}$  at these temperatures is expected as it agrees well with the Cu phase diagrams and other reports.<sup>27-28</sup> During the  $\text{CuAlO}_2$  film formation excess  $\text{Cu}_2\text{O}$  is clearly evident on the sample surface even after several hours annealing. From this we conclude that the reaction atmosphere plays a critical role in the formation of  $\text{CuAlO}_2$ . The stagnant atmosphere of the heating stage graphite dome inhibits the reaction between the CuO or  $\text{Cu}_2\text{O}$  and  $\text{Al}_2\text{O}_3$ . The gaseous Cu components reduce the oxygen partial pressure sufficiently so as to drive the reaction equilibrium towards the



decomposition of  $\text{Cu}_2\text{O}$ . In an open atmosphere, the Cu vapour can equilibrate with surrounding air, stopping the decomposition process thus allowing the  $\text{Cu}_2\text{O}$  to react with the  $\text{Al}_2\text{O}_3$ , as would be expected by the ternary phase diagram for this system.<sup>20</sup> This suggests that an optimum annealing procedure would consist of two stages with the initial heating being conducted at low oxygen partial pressure so as to encourage the rapid decomposition of  $\text{CuO}$ , followed by a prolonged anneal at atmospheric oxygen partial pressures so as to enable the reaction between  $\text{Cu}_2\text{O}$  and  $\text{Al}_2\text{O}_3$ . Furthermore, the dependence on annealing atmosphere also suggests that it may be possible to convert previously formed  $\text{CuAlO}_2$  films to a MCC via a thermal decomposition route. The distinct advantage of this route lies in the fact that the Cu and Al are already intimately mixed at the atomic level, and are of equal stoichiometry, which should yield highly conductive MCCs.

### 3.3 Cu- $\text{Al}_2\text{O}_3$ MCC

Figure 4(b) shows the in situ XRD data for a  $\text{CuAlO}_2$  film annealed at  $1100^\circ\text{C}$ . Prior to annealing, the film consisted primarily of  $\text{CuAlO}_2$ , with a small amount of spinel impurity and a trace amount of  $\text{CuO}$ . The sample was then rapidly heated to the target temperature before scans were commenced. During the first 8 minutes (figure 4(b) curve (ii)), there is a noticeable reduction in the  $\text{CuAlO}_2$  peak intensities with respect to the substrate peaks. A new peak emerges at  $2\theta = 32.6^\circ$ , which is identified from room temperature scans as due to the AlN heating stage. Between the 8<sup>th</sup> and 16<sup>th</sup> minutes of the anneal, the  $\text{CuAlO}_2$  film peaks reduced markedly in intensity to the limit of detection. Room temperature XRD post annealing, (figure 4(c) curve (ii)) shows that the sample is now largely composed of  $\text{Al}_2\text{O}_3$  and metallic Cu, which was confirmed by SEM and EDX analysis as shown in figure 5 (a)-(d). Similar to the  $\text{CuO}$  annealed samples, a number of weaker additional diffractions were detected at  $2\theta = 19.5^\circ, 31.6^\circ, 32.8^\circ, 35.7^\circ, 36.8^\circ, 37.7^\circ, 44.8^\circ, 45.4^\circ, 49.5^\circ, 51.4^\circ$  and  $59.1^\circ$ . Given the initial composition of the film prior to annealing, the most likely origin of most of the weaker impurity phases are residual  $\text{CuAlO}_2$ ,  $\text{CuAl}_2\text{O}_4$ ,  $\text{Al}_2\text{O}_3$  and  $\text{CuO}$ , which have diffraction peaks in reasonable agreement with those detected.

Post annealing the films are composed of large crystals, with some evidence of faceting, coated by a dusting of smaller well faceted material. EDX analysis of many of these smaller well faceted crystallites indicate that they are composed of reduced metallic copper (figure 5a). The larger grains, which constitute the bulk of the film structure are composed of a composite of Cu and  $\text{Al}_2\text{O}_3$ . EDX analysis of grains free from metallic copper coating (figure 5(b)) confirm the stoichiometry of Cu to Al to O as 1:2:3, matching the expected stoichiometry of a Cu- $\text{Al}_2\text{O}_3$  MCC. The individual grains of the films appear stratified, being composed of alternating layers, with clear contrast differences in some regions, as shown in the images in figures 5(b) - (d). The alternating crystal structure of the  $\text{CuAlO}_2$  precursor very possibly plays an important role in the formation of layering.

Under these preparation conditions, the  $\text{CuAlO}_2$  film decomposes, which in turn leads to the reduction of the  $\text{Cu}^{+1}$  state yielding elemental Cu metal. It is interesting to note that the previously reported phase diagram suggests that  $\text{CuAlO}_2$  at atmospheric conditions should be stable above  $1100^\circ\text{C}$  and  $1140^\circ\text{C}$  is the temperature often used to oxidise Cu to form  $\text{Cu}_2\text{O}$

single crystals.<sup>20,25,29</sup> Experiments performed in open atmospheric conditions confirm the stability of the films up to these temperatures. Therefore a temperature rise or overshoot is unlikely to lead to the decomposition of the  $\text{CuAlO}_2$  film. Similarly, from the phase diagram it is seen that reducing the temperature range below circa  $1000^\circ\text{C}$  at atmospheric conditions decomposes  $\text{CuAlO}_2$  into  $\text{CuAl}_2\text{O}_4$  and  $\text{CuO}$ .<sup>20,25</sup> In this work, both  $\text{CuO}$  films and  $\text{CuAlO}_2$  films, were observed in situ, reducing to Cu and  $\text{Cu} + \text{Al}_2\text{O}_3$  respectively. It is well known that the composition of  $\text{Cu}_x\text{O}$  melts are dependant on the  $\text{O}_2$  partial pressure. At atmospheric oxygen partial pressures, at  $1100^\circ\text{C}$  the  $\text{CuO}$  stability diagram for this system predicts that the final product is  $\text{Cu}_2\text{O}$  with Cu only forming at significantly lower partial pressures.<sup>30</sup> Phase diagram measurements are typically made for bulk materials and therefore the Cu- $\text{Cu}_2\text{O}$ -CuO system reported in reference 30, may not be direct applicable to this system given that the  $\text{CuAlO}_2$  is decomposing at an atomic level. At present we are unaware of any reported phase diagrams for the  $\text{CuAlO}_2$  system at reduced oxygen partial pressures which may explain the anomalous decomposition temperature.

Four point probe electrical measurements in the van der Pauw configuration on these films confirm that they are conductive with a sheet resistance  $\sim 1.6 \Omega/\square$ , giving a bulk resistivity of the order of 2-5  $\text{m}\Omega\text{cm}^{-1}$ , based on the experimentally determined maximum and minimum film thickness. Given that the phase pure copper identified by EDX on the film surface only forms a discontinuous dusting, it is unlikely to contribute much to the overall film conductivity. Both  $\text{Cu}_2\text{O}$  and  $\text{CuO}$  are well know p-type semiconductors. The question then arises whether the conductivity is due to the presence of residual oxides or metallic Cu. The lowest reported resistivity for  $\text{Cu}_2\text{O}$  that we are aware of is  $12 \Omega\text{cm}^{-1}$ , for high quality Si doped single crystals, which is orders of magnitude lower than that of bulk single crystals of  $\text{CuO}$ .<sup>31,32</sup> Given that our films are polycrystalline and that the resistivity is orders of magnitude lower than that of high quality single crystal  $\text{Cu}_2\text{O}$ , it is also highly unlikely that the conductivity arises from residual oxides. Therefore we speculate that the conductivity arises within the large stratified grains of the material, due to the metallic Cu. However our data are insufficient to comment further at present as to whether the stratifications are linked to the conduction mechanism and the associated issue of the exact distribution of the metallic Cu within the large grains.

## 4. Conclusions

We have demonstrated that phase pure  $\text{CuAlO}_2$  powders can be produced in a simple and scalable manner using boehmite and  $\text{CuO}$  precursors and adjusting the stoichiometry of the starting materials to ensure complete consumption of the boehmite.  $\text{CuAlO}_2$  films were also produced using a novel molten nitrate salt painting process, the simplicity of which could easily be adapted to coating complex ceramic geometries. To further understand the formation mechanism the reactions of  $\text{CuO}$  with  $\text{Al}_2\text{O}_3$  were monitored in situ at high temperature by XRD and this study revealed that the annealing atmosphere plays a critical role in both the formation of  $\text{CuAlO}_2$  and its spinel impurity phase. Based on this, a method was developed to convert the  $\text{CuAlO}_2$  into a conductive MCC film with an unusual

(micro/nano) structure via thermal decomposition. Further work is currently underway to examine the tribological and mechanical properties of the MCC films and the possibility of using pressed CuAlO<sub>2</sub> powders to form conductive MCC parts for advanced ceramic applications. Further work is also necessary to clarify the details of the MCC (micro/nano) structure and conduction mechanism.

## 5. Acknowledgments

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## References

- (1) Banerjee, A. N.; Nandy, S.; Ghosh, C. K.; Chattopadhyay, K. K. *Thin Solid Films* **2007**, *515* (18) 7324-7330
- (2) Ling, B.; Sun, X. W.; Zhao, J. L.; Tan, S. T.; Dong, Z. L.; Yang, Y.; Yu, H. Y.; Qi, K. C. *Physica E: Low-dimensional Systems and Nanostructures* **2009**, *41* (4) 635-639
- (3) Ling, B.; Zhao, J. L.; Sun, X. W.; Tan, S. T.; Kyaw, A. K. K.; Divayana, Y.; Dong, Z. L. *Applied Physics Letters* **2010**, *97* (1) 013101-013101-013103
- (4) Kawazoe, H.; Yasukawa, M.; Hyodo, H.; Kurita, M.; Yanagi, H.; Hosono, H. *Nature* **1997**, *389* (6654) 939-942
- (5) Mondelli, C.; Amrute, A. P.; Schmidt, T.; Perez-Ramirez, J. *Chem Commun* **2011**, *47* (25) 7173-7175
- (6) Smith, J. R.; Van Steenkiste, T. H.; Wang, X.-G. *Phys Rev B* **2009**, *79* (4) 041403
- (7) Arghya Narayan, B.; Sang, W. J. *Nanotechnology* **2011**, *22* (36) 365705
- (8) Zheng, X. G.; Taniguchi, K.; Takahashi, A.; Liu, Y.; Xu, C. N. *Applied Physics Letters* **2004**, *85* (10) 1728-1729
- (9) Jamaati, R.; Toroghinejad, M. R. *Materials Science and Engineering: A* **2010**, *527* (27-28) 7430-7435
- (10) Shehata, F.; Fathy, A.; Abdelhameed, M.; Moustafa, S. F. *Materials & Design* **2009**, *30* (7) 2756-2762
- (11) Fathy, A.; Shehata, F.; Abdelhameed, M.; Elmahdy, M. *Materials & Design* **2012**, *36* (0) 100-107
- (12) Ding, J.; Sui, Y.; Fu, W.; Yang, H.; Liu, S.; Zeng, Y.; Zhao, W.; Sun, P.; Guo, J.; Chen, H.; Li, M. *Applied Surface Science* **2010**, *256* (21) 6441-6446
- (13) Deng, Z.; Zhu, X.; Tao, R.; Dong, W.; Fang, X. *Materials Letters* **2007**, *61* (3) 686-689
- (14) Shahriari, D. Y.; Barnabè, A.; Mason, T. O.; Poepelmeier, K. R. *Inorganic Chemistry* **2001**, *40* (23) 5734-5735
- (15) Ingram, B. J.; González, G. B.; Mason, T. O.; Shahriari, D. Y.; Barnabè, A.; Ko, D.; Poepelmeier, K. R. *Chem Mater* **2004**, *16* (26) 5616-5622
- (16) Neumann-Spallart, M.; Pai, S. P.; Pinto, R. *Thin Solid Films* **2007**, *515* (24) 8641-8644
- (17) Wang, Y.; Gong, H.; Zhu, F.; Liu, L.; Huang, L.; Huan, A. C. H. *Materials Science and Engineering: B* **2001**, *85* (2-3) 131-134
- (18) Ishiguro, T.; Kitazawa, A.; Mizutani, N.; Kato, M. *Journal of Solid State Chemistry* **1981**, *40* (2) 170-174
- (19) Tate, J.; Ju, H. L.; Moon, J. C.; Zakutayev, A.; Richard, A. P.; Russell, J.; McIntyre, D. H. *Phys Rev B* **2009**, *80* (16)
- (20) Jacob, K. T.; Alcock, C. B. *J Am Ceram Soc* **1975**, *58* (5-6) 192-195
- (21) Jiang, H. F.; Lei, H. C.; Zhu, X. B.; Li, G.; Yang, Z. R.; Song, W. H.; Dai, J. M.; Sun, Y. P.; Fu, Y. K. *Journal of Alloys and Compounds* **2009**, *487* (1-2) 404-408
- (22) Shy, J. H.; Tseng, B. H. *Journal of Physics and Chemistry of Solids* **2005**, *66* (11) 2123-2126
- (23) Shy, J. H.; Tseng, B. H. *Journal of Physics and Chemistry of Solids* **2008**, *69* (2-3) 547-550
- (24) Thu, T. V.; Thanh, P. D.; Suekuni, K.; Hai, N. H.; Mott, D.; Koyano, M.; Maenosono, S. *Materials Research Bulletin* **2011**, *46* (11) 1819-1827
- (25) Susnitzky, D. W.; Carter, C. B. *J Mater Res* **1991**, *6* (9) 1958-1963
- (26) Song, J.-H.; Lee, J.-A.; Lee, J.-H.; Heo, Y.-W.; Kim, J.-J. *Ceram Int* (0)
- (27) Schramm, L.; Behr, G.; Loser, W.; Wetzig, K. *J Phase Equilib Diff* **2005**, *26* (6) 605-612
- (28) Fujimura, T.; Tanaka, S.-I. *Acta Materialia* **1998**, *46* (9) 3057-3061
- (29) Toth, R. S.; Kilkson, R.; Trivich, D. *Journal of Applied Physics* **1960**, *31* (6) 1117-1121
- (30) Neumann, J. P.; Zhong, T.; Chang, Y. A. *Bulletin of Alloy Phase Diagrams* **1984**, *5* (2) 136-140
- (31) Ishizuka, S.; Kato, S.; Okamoto, Y.; Akimoto, K. *Applied Physics Letters* **2002**, *80* (6) 950-952
- (32) Zheng, X. G.; Suzuki, M.; Xu, C. N. *Materials Research Bulletin* **1998**, *33* (4) 605-610